plate or methyl methacrylate copolymer. Polymer(s) corresponding to (A) and (B) are blended to become (B) content in (I) to 0.07-1.07 (I) absorbs near infrared ray selectively. Using (I), (II) or (III), (2) an optical filter(III) for plasma display comprising (I) or (II) and (1) an optical filter(II) for plasma display comprising (I) and one of electrically conductive layer, antistatic layer or reflection insulating (A) is film(s) or sheet(s) of methyl methacrylate homopolymer clear image of plasma display is obtained, errors of electrical and electronic instruments can be avoided by using (I), (II) or (III) A(4-F1A, 12-L3D) E(5-L2C) G(6-A3, 6-A11, 6-F4, 6glass plate or plastic plate(s) to support (I) or (II). R1-R4= H or methoxy independently. Also claimed, are **EMBODIMENT ADVANTAGE** FS) L(3-G5) layer; and *JP 11012425-A MITR 97.06.23 Optical filter(I) for plasma display comprising (A) and (B) is claimed. 97.06.23 97JP-165923 (99.01.19) C08L 33/00, C08K 5/36, C09K 3/00, G02B 5/22, H01J 11/02, F21V 9/04, C08K 5/56 // C08J 5/00 (A): acrylic resin film(s) or sheet(s) (B): nickel complex(es) of A89 E23 G06 L03 Optical filter for plasma display. MITSUBISHI RAYON CO LTD C99-044043 99-148685/13 formula (I):

(I) or (II) is formed on glass or plastic plate(s) g/m², the mixt. moulded to film(s) or sheet(s) to obtain (I). One of layer), antistatic layer(e.g. surface active agent layer) or reflection electrically conductive layer(e.g. silver thin layer and/or ITO thin insulating layer(e.g. silica layer, titania layer etc) is formed on (I) surface to obtain (II). (I) or (II) is formed on glass or plastic plat to obtain (III).

EMBODIMENT

Acrypet VH(RTM), the mixt. was moulded to film containing (B1) 0.39 g/m² to obtain (I). (I) showed transmittance 15 % at 920 nm, 68

% at 450-680 nm region. (KR) (4pp129DwgNo.0/0) | TD 1101242